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**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

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Sheet 1 of 1

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|------------------------|-----------------------|
| Application Number | 10/042,143 |
| Filing Date | 01/11/2002 |
| First Named Inventor | Lin, Wei |
| Group Art Unit | 2155 |
| Examiner Name | Baturay, Alicia |
| Attorney Docket Number | 2000-0672A (1014-200) |

PUBLISHED U.S. PATENT DOCUMENTS

| Examiner Initials | Application or Patent Number | Name of Applicant or Patentee | Date of Publication |
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Examiner
Signature

/Alicia Baturay/

Date
Considered

06/27/2007

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¹ Unique citation designation number. ² Applicant is to place a check mark here if English language Translation is attached.

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